

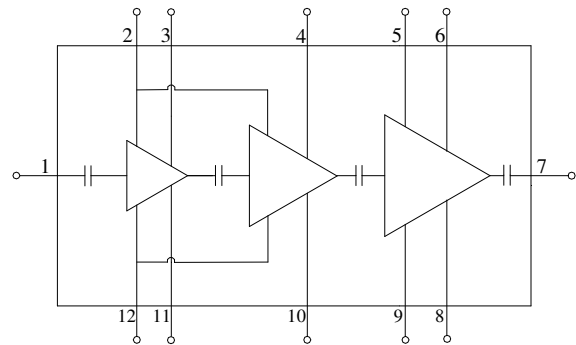
Applications

- Test Instrumentation
- Electronic Warfare (EW)
- Radar
- Communications

Product Features

- Frequency Range: 6 – 18GHz
- P_{OUT}: >43dBm @ P_{IN} = 23dBm
- PAE: >20% @ P_{IN} = 23dBm
- Large Signal Gain: >20dB @ P_{IN} = 23dBm
- Small Signal Gain: >26dB
- Return Loss: >6.5dB
- Bias: V_D = 20V, I_{DQ} = 2500mA, V_G = -2.3V Typical
- Chip Dimensions: 5.4 x 6.85 x 0.10 mm

Functional Block Diagram



General Description

Qorvo's TGA2963 is a broadband high power MMIC amplifier fabricated on Qorvo's production 0.15um GaN on SiC process (QGAN15). The TGA2963 operates from 6 – 18GHz and provides more than 20W saturated output power with power-added efficiency >20% and large-signal gain >20 dB. This combination of wideband performance provides the flexibility designers are looking for to improve system performance while reducing size and cost.

The TGA2963 is matched to 50Ω with integrated DC blocking capacitors on both RF I/O ports simplifying system integration. The broadband performance makes it ideally suited in support of test instrumentation and electronic warfare, as well as, supporting multiple radar and communication bands.

The TGA2963 is 100% DC and RF tested on-wafer to ensure compliance to electrical specifications.

Lead-free and RoHS compliant.

Evaluation boards are available upon request.

Pad Configuration

Pad No.	Symbol
1	RF In
2, 12	V _{G12}
3, 11	V _{D1}
4, 10	V _{D2}
5, 9	V _{G3}
6, 8	V _{D3}
7	RF Out

Ordering Information

Part	ECCN	Description
TGA2963	3A001.b.2.c	6 – 18GHz 20W GaN Power Amplifier

Absolute Maximum Ratings

Parameter	Value
Drain Voltage (V_D)	29.5V
Gate Voltage Range (V_G)	-8 to 0V
Drain Current (I_{D1})	960mA
Drain Current (I_{D2})	1440mA
Drain Current (I_{D3})	5760mA
Gate Currents ($I_{G1}/I_{G2}/I_{G3}$)	See plot on page 3
Power Dissipation (P_{DISS}), 85°C, CW	150W
Input Power (P_{IN}), 50Ω, $V_D = 20V$, $I_{DQ} = 2500$ mA, 85°C, CW	30dBm
Input Power (P_{IN}), VSWR 3:1, $V_D = 20V$, $I_{DQ} = 2500$ mA, 85°C, CW	30dBm
Channel Temperature (T_{CH})	275°C
Mounting Temperature (30 seconds)	320°C
Storage Temperature	-55 to 150°C

Operation of this device outside the parameter ranges given above may cause permanent damage. These are stress ratings only, and functional operation of the device at these conditions is not implied.

Recommended Operating Conditions

Parameter	Value
Drain Voltage (V_D)	20V
Drain Current (I_{DQ})	2500mA (Total)
Gate Voltage (V_G)	-2.3V (Typ.)

Electrical specifications are measured at specified test conditions. Specifications are not guaranteed over all recommended operating conditions.

Electrical Specifications

Test conditions unless otherwise noted: 25°C, $V_D = 20V$, $I_{DQ} = 2500mA$, $V_G = -2.3V$ Typical

Parameter	Min	Typical	Max	Units
Operational Frequency Range	6		18	GHz
Small Signal Gain		>26		dB
Input Return Loss		>8		dB
Output Return Loss		>6.5		dB
Power Gain ($P_{in} = 23dBm$)		>20		dB
Output Power ($P_{in} = 23dBm$)		>43		dBm
Power Added Efficiency ($P_{in} = 23dBm$)		>20		%
Small Signal Gain Temperature Coefficient		-0.062		dB/°C
Output Power Temperature Coefficient		-0.017		dBm/°C

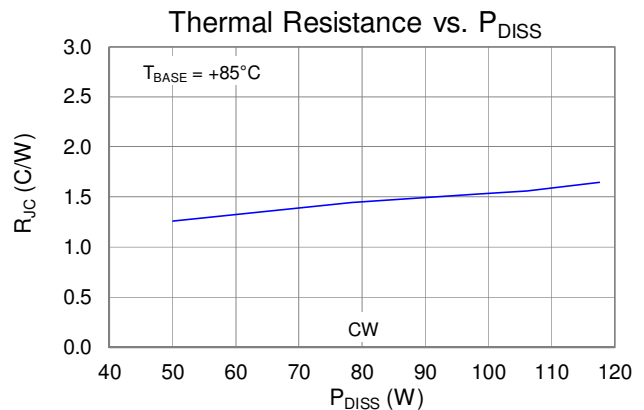
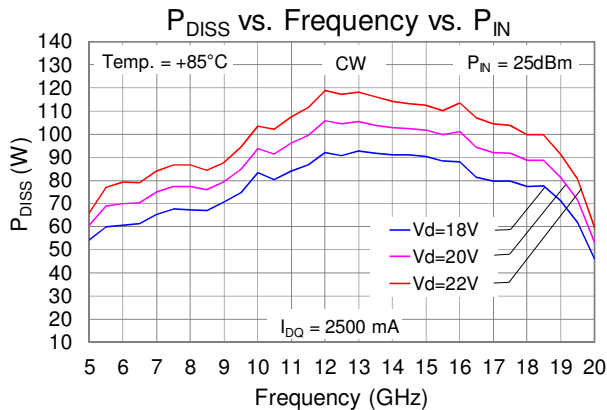
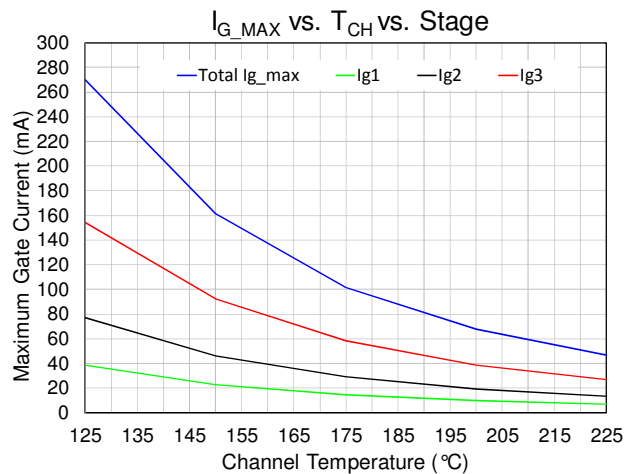
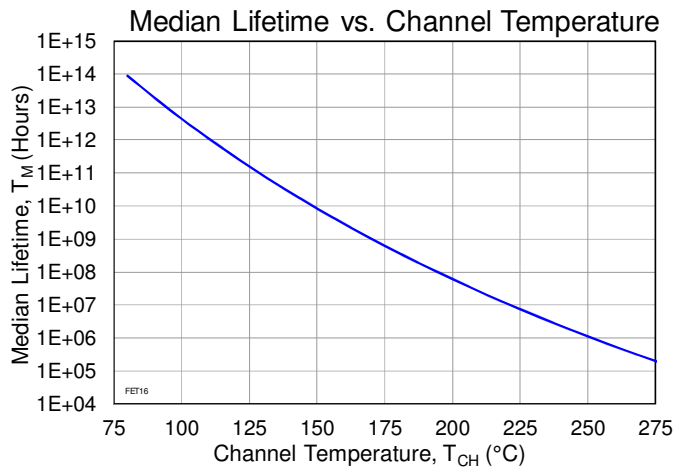
Thermal and Reliability Information

Parameter	Test Conditions	Value	Units
Thermal Resistance (θ_{JC}) ⁽¹⁾	$T_{base} = 85^\circ\text{C}$, CW	1.26	$^\circ\text{C}/\text{W}$
Channel Temperature (T_{CH}) (No RF drive)	$V_D = 20\text{V}$, $I_{DQ} = 2500\text{mA}$	148	$^\circ\text{C}$
Median Lifetime (T_M)	$P_{DISS} = 50\text{W}$	1.1×10^{10}	Hrs
Thermal Resistance (θ_{JC}) ⁽¹⁾	$T_{base} = 85^\circ\text{C}$, $V_D = 20\text{V}$, $I_{DQ} = 2500\text{mA}$, CW	1.56	$^\circ\text{C}/\text{W}$
Channel Temperature (T_{CH}) (Under RF drive)	$I_{D_Drive} = 6.6\text{A}$, Freq = 12GHz	250	$^\circ\text{C}$
Median Lifetime (T_M)	$P_{IN} = 25\text{dBm}$, $P_{OUT} = 45\text{dBm}$, $P_{DISS} = 106\text{W}$	1.1×10^6	Hrs

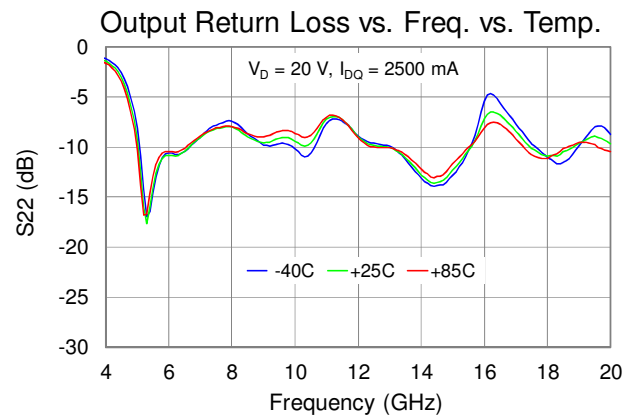
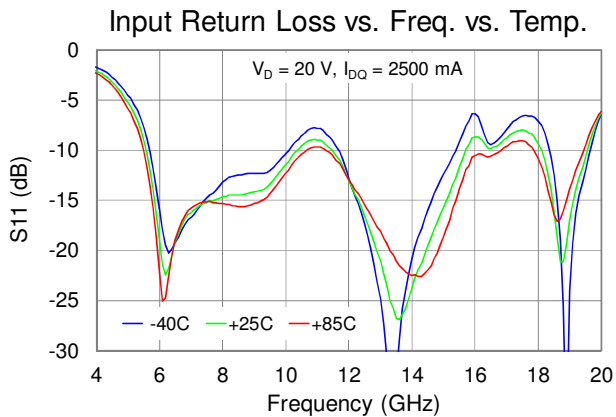
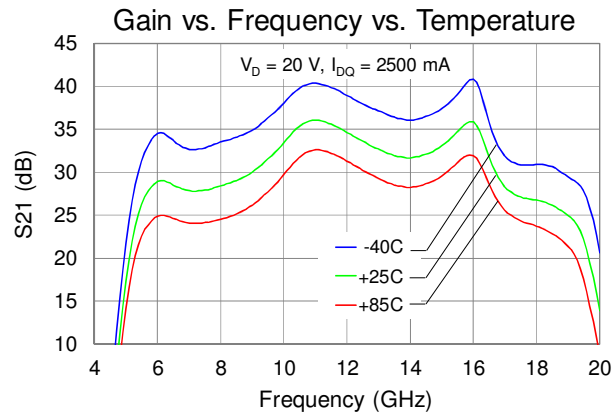
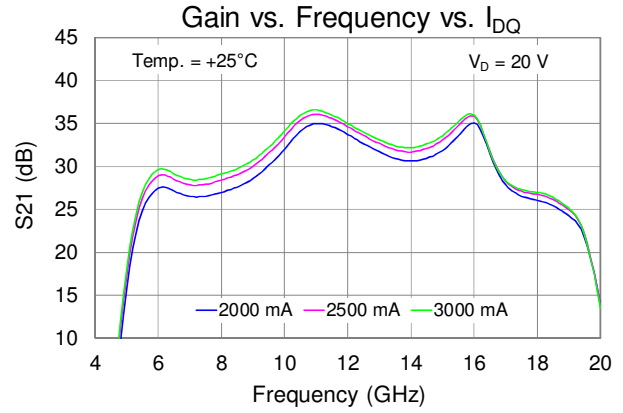
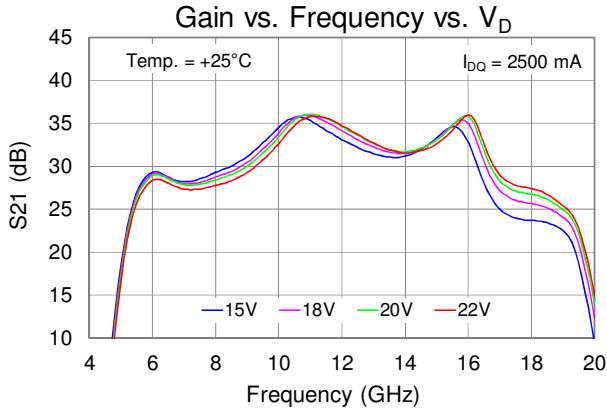
Notes:

1. Thermal resistance measured to back of carrier plate. MMIC mounted on 40 mils CuMo (CM15) carrier using 1.5 mil AuSn.

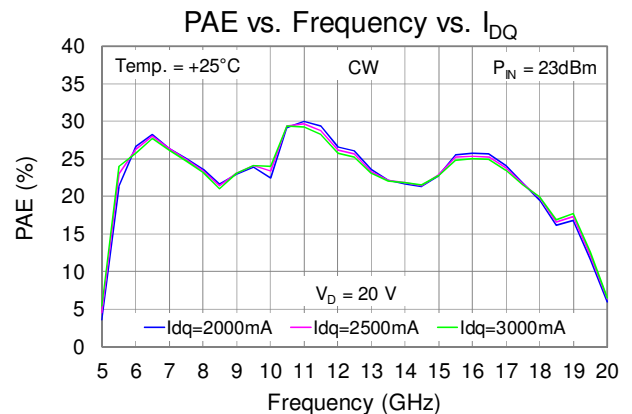
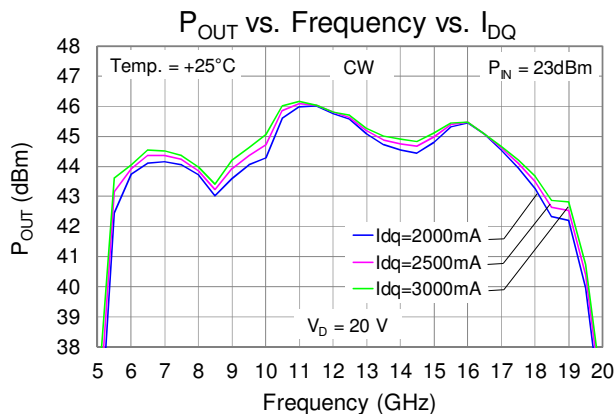
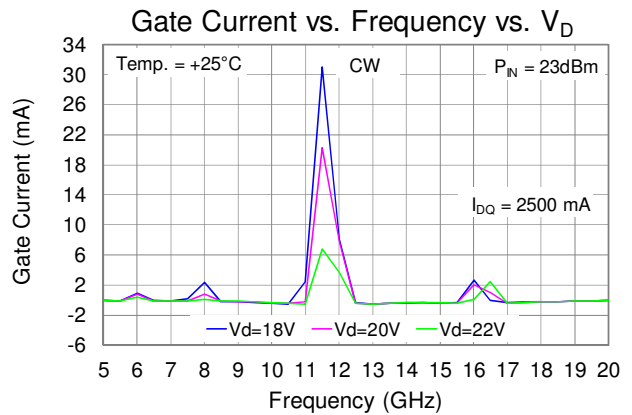
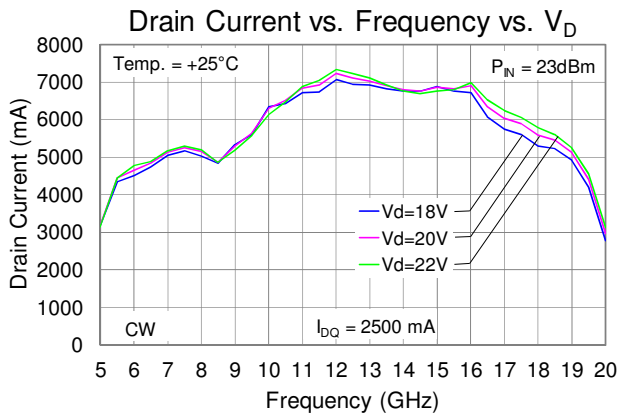
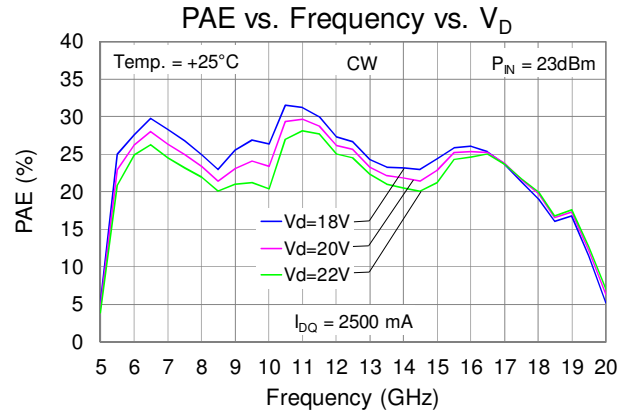
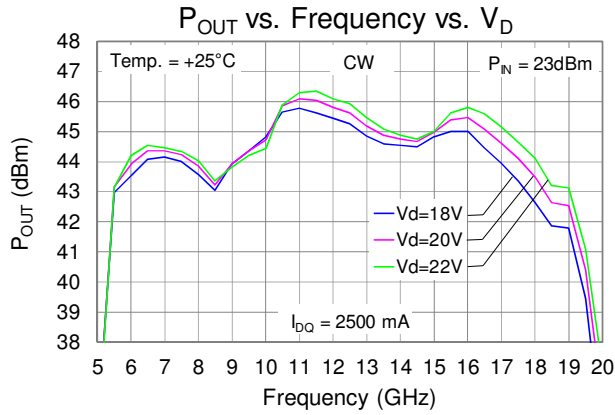
Test Conditions: $V_D = 28\text{V}$; Failure Criteria = 10% reduction in I_{D_MAX}



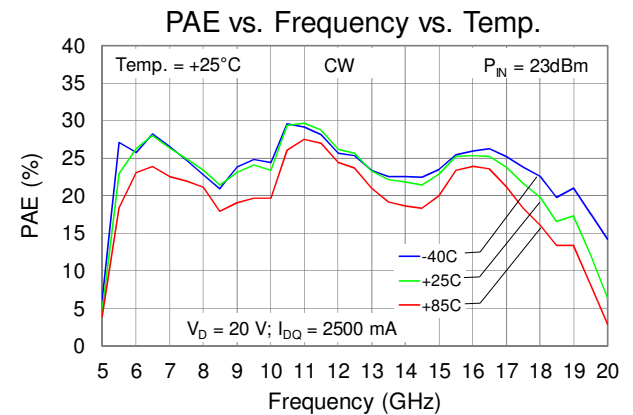
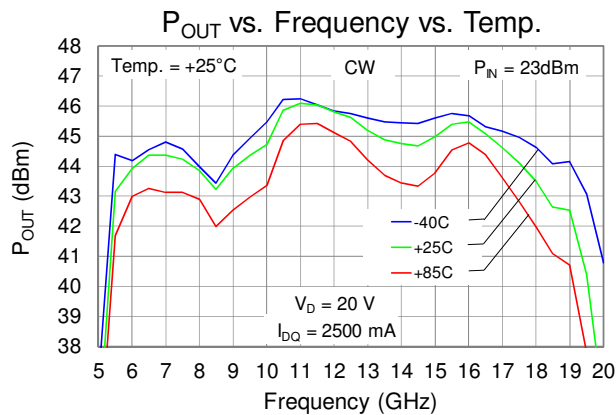
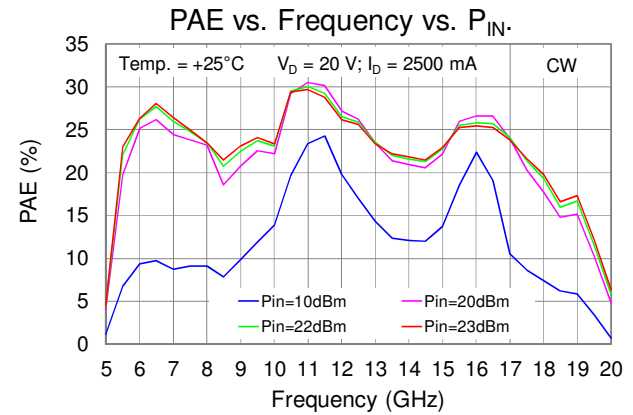
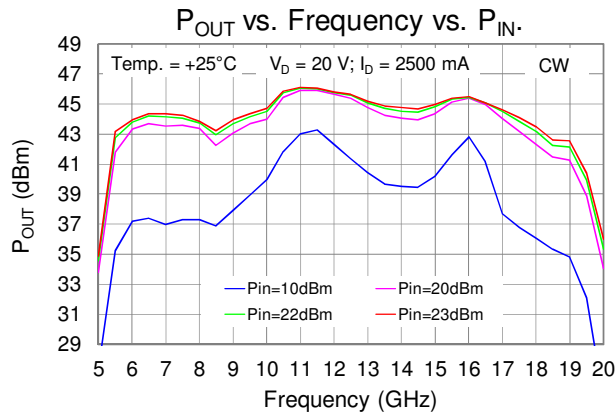
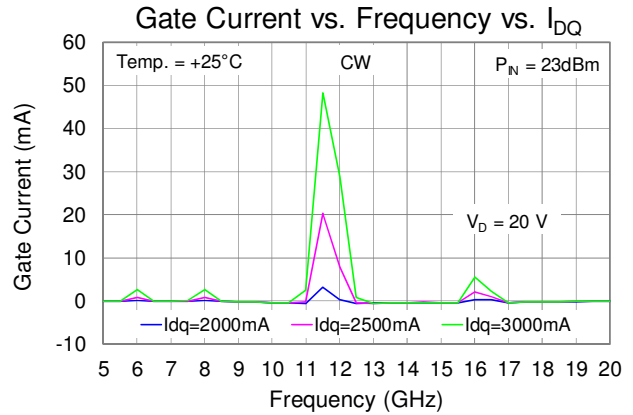
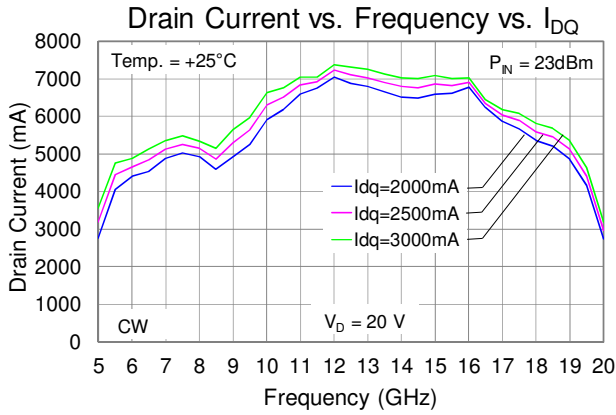
Typical Performance (Small Signal)



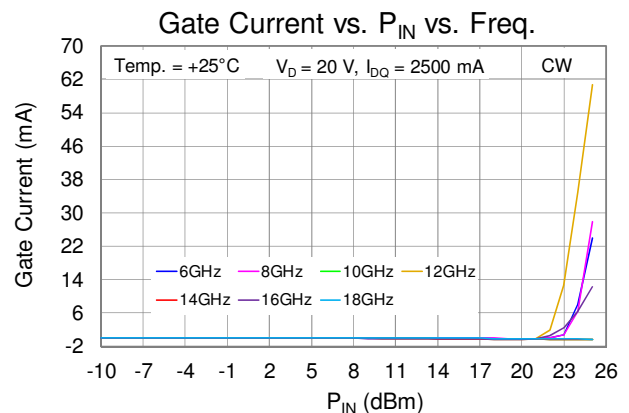
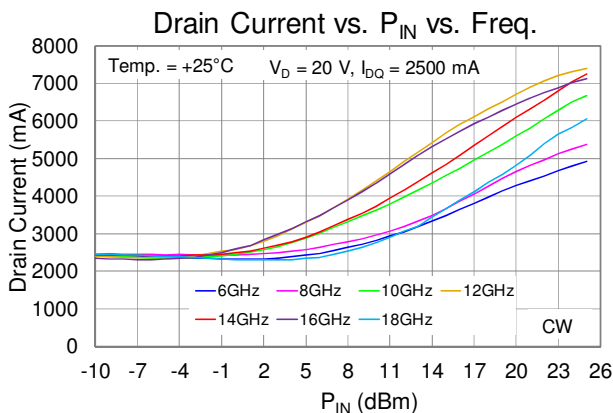
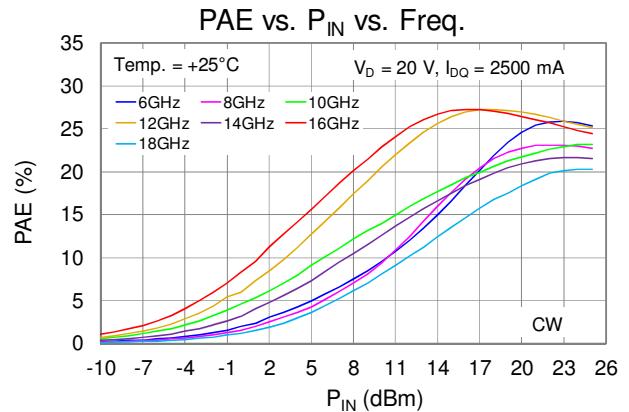
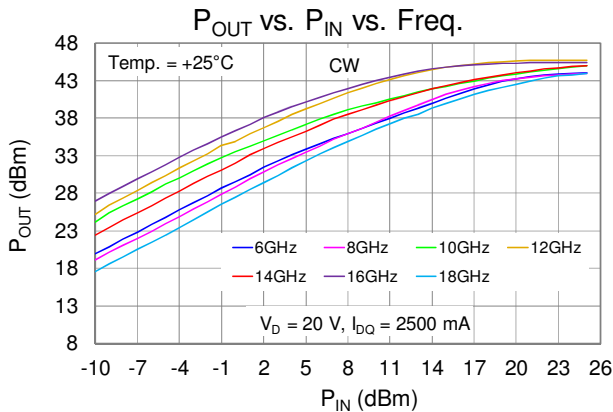
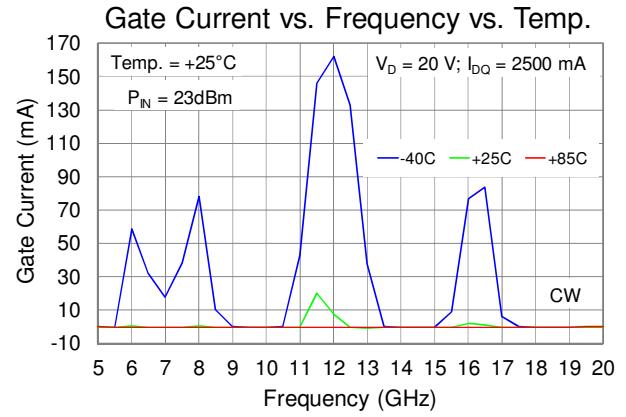
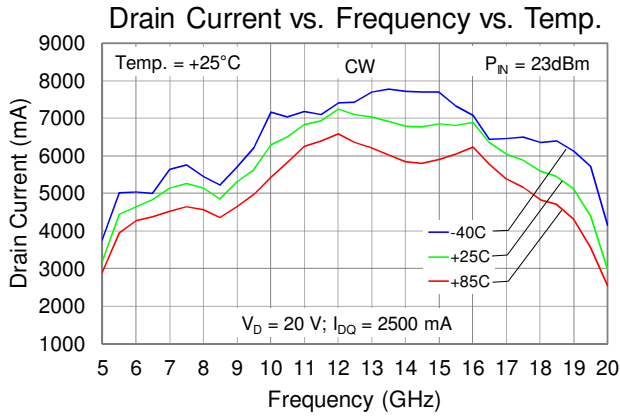
Typical Performance (Large Signal CW)



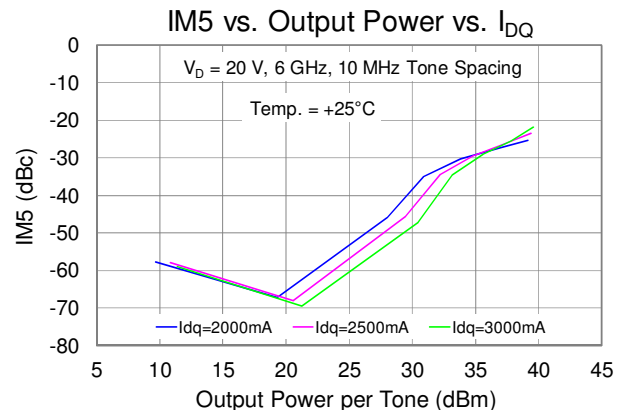
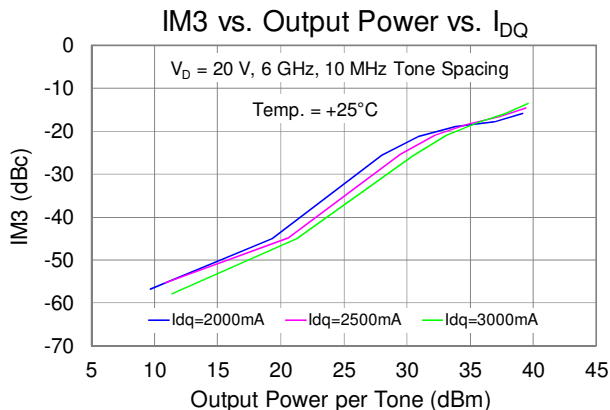
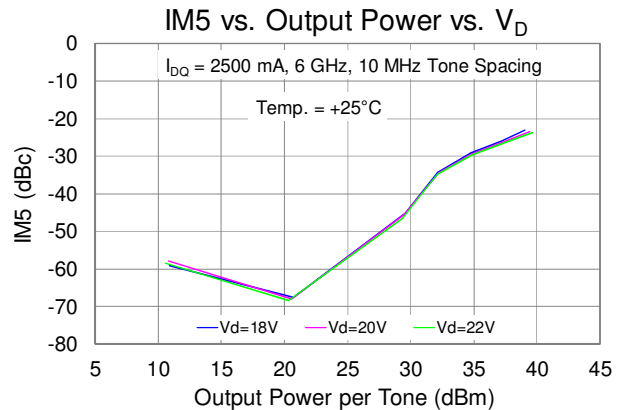
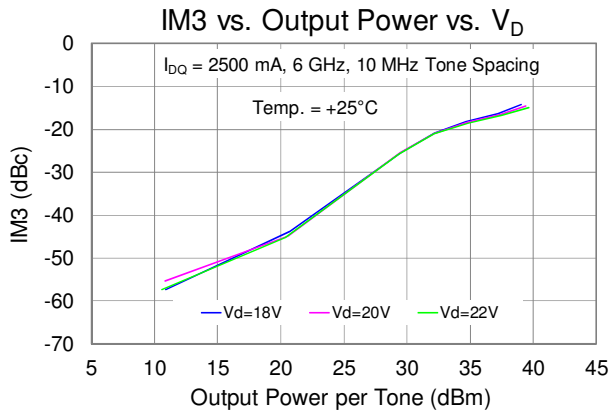
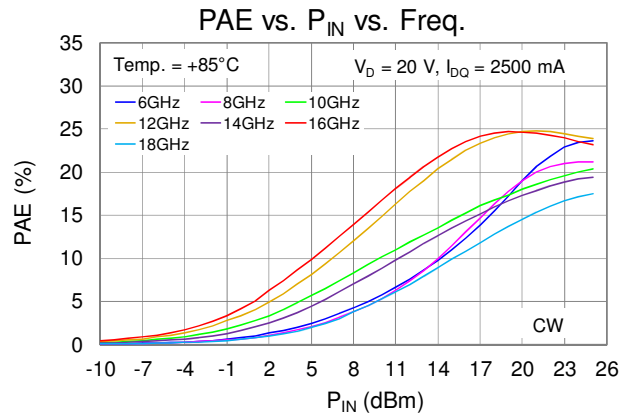
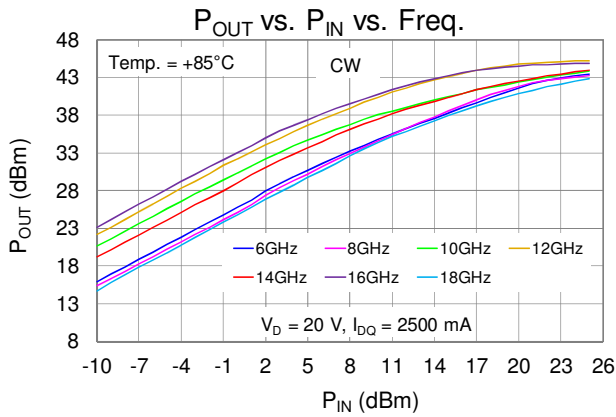
Typical Performance (Large Signal CW)



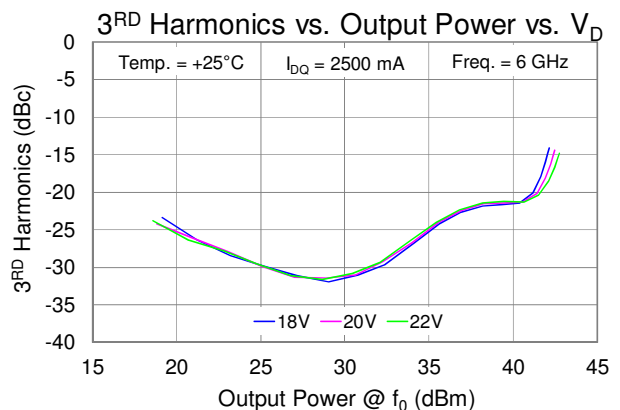
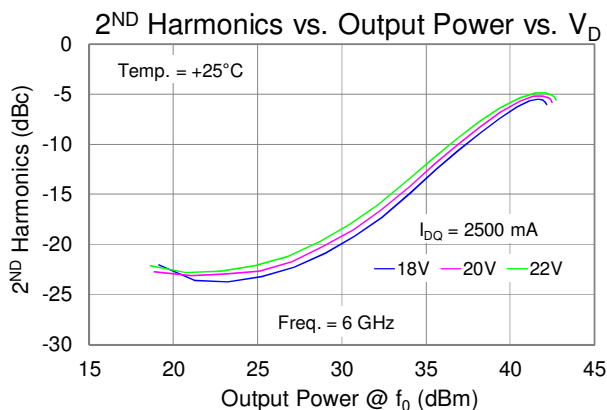
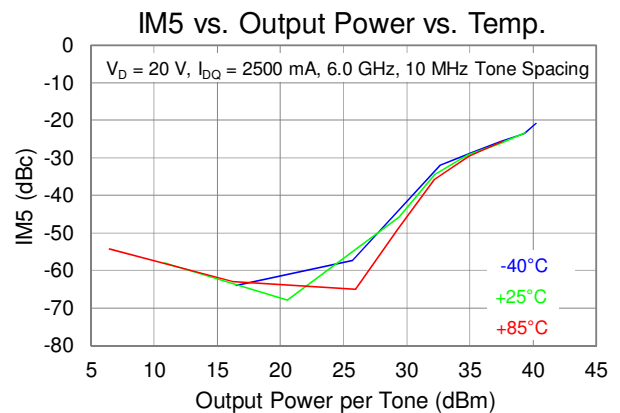
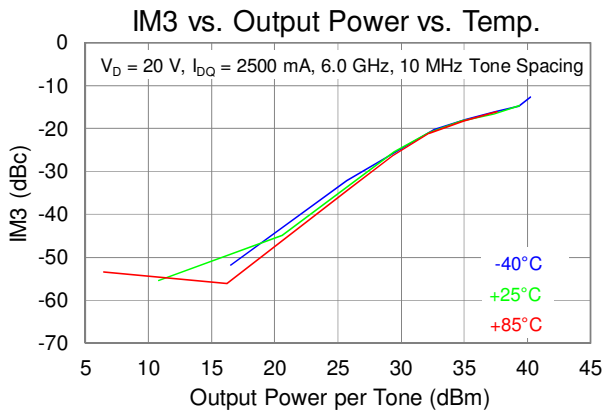
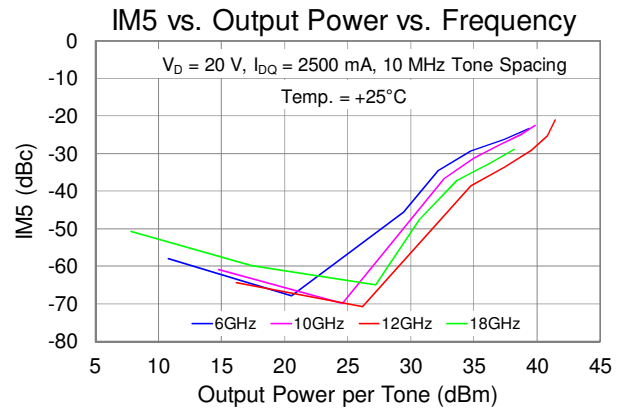
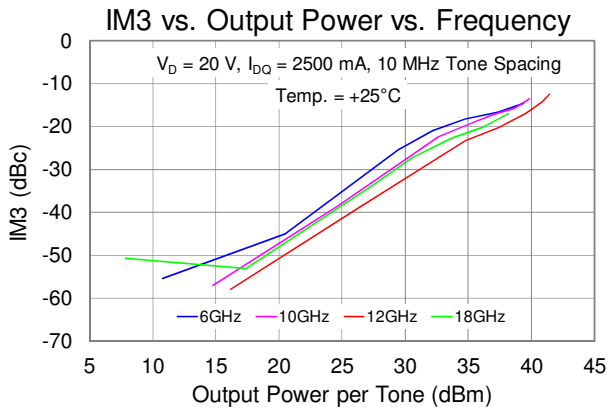
Typical Performance (Large Signal CW)



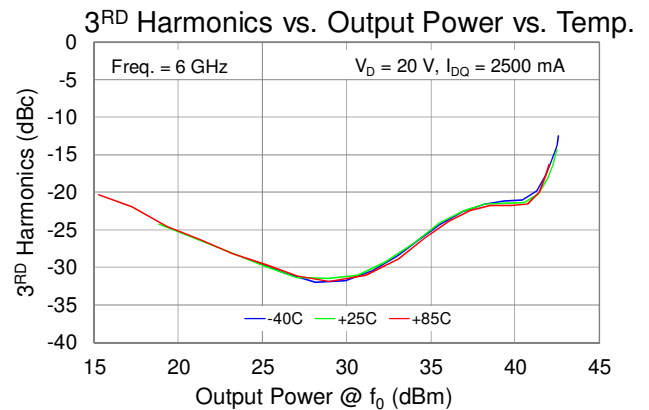
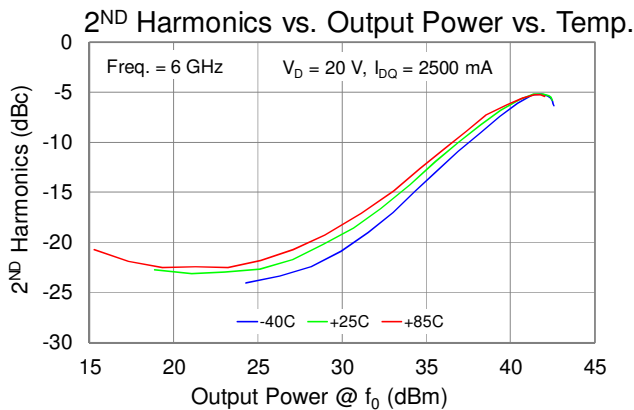
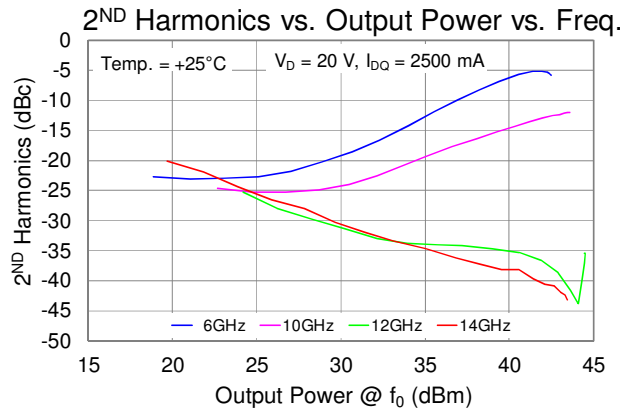
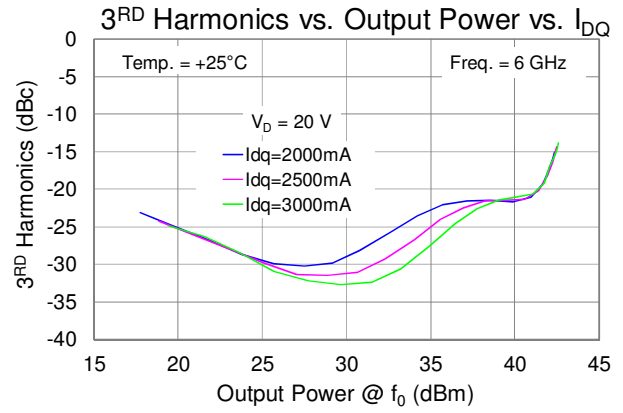
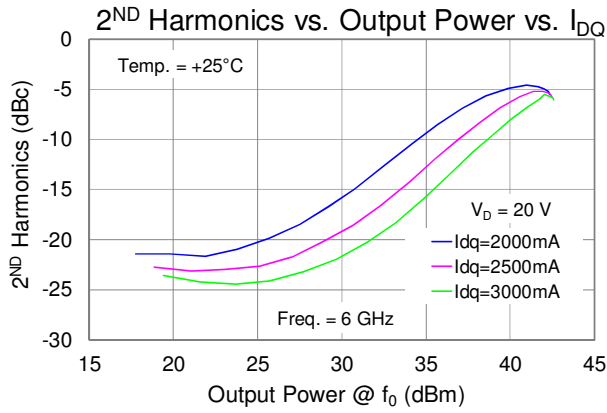
Typical Performance (Large Signal & Linearity)



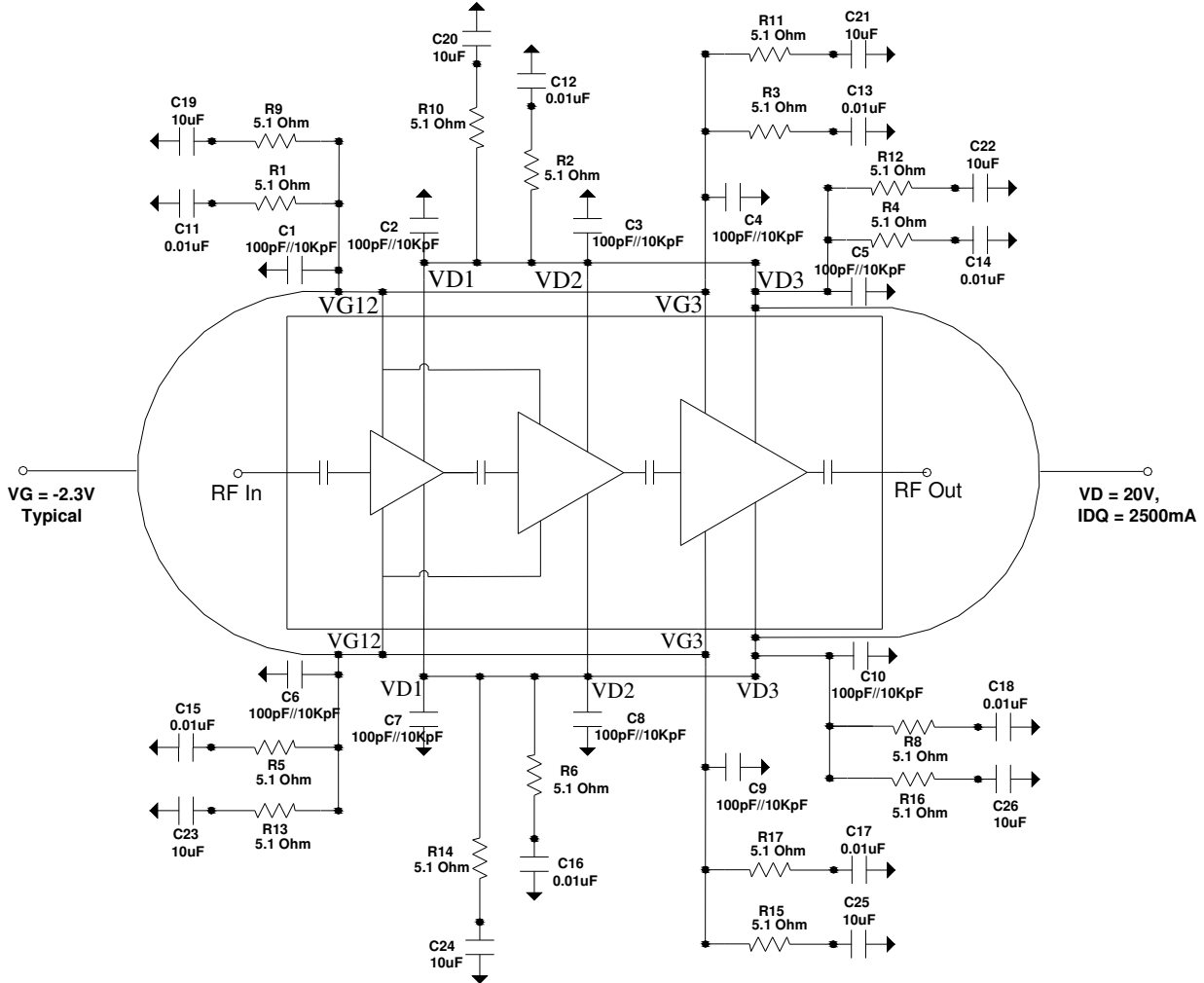
Typical Performance (Linearity)



Typical Performance (Linearity)



Application Circuit



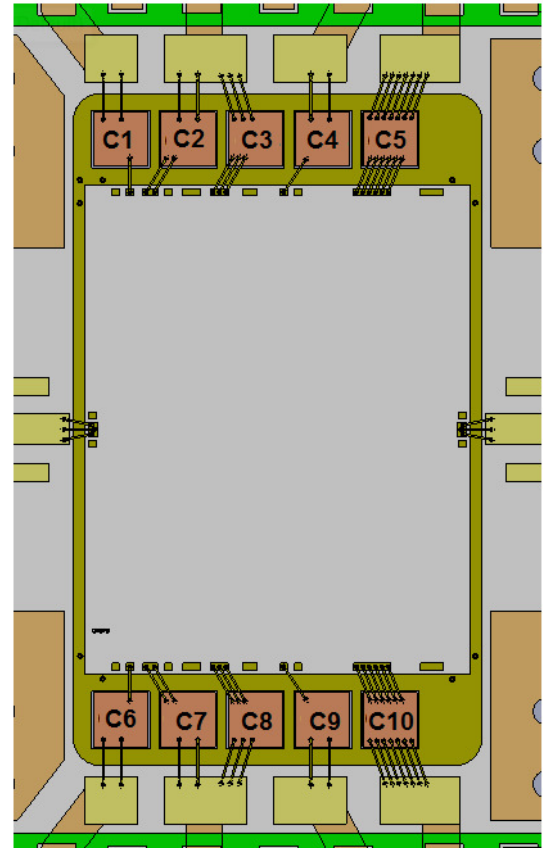
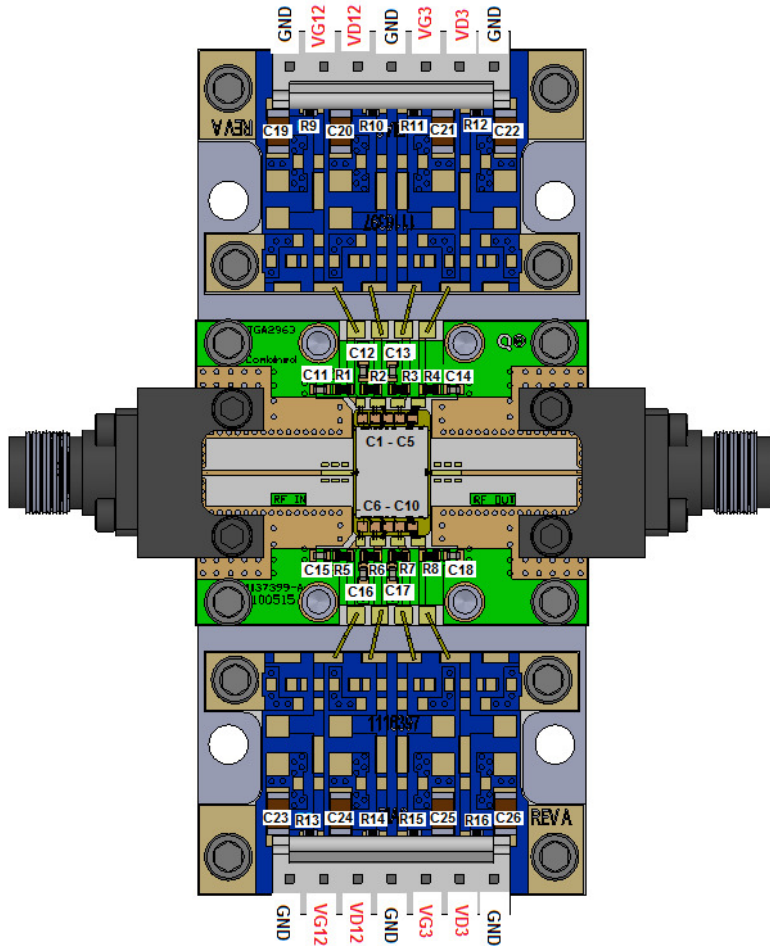
Bias-up Procedure

1. Set I_D limit to 8A, I_G limit to 50mA
2. Set V_G to -5.0V
3. Set V_D +20V
4. Adjust V_G more positive until $I_{DQ} = 2500mA$ ($V_G \sim -2.3V$ Typical)
5. Apply RF signal

Bias-down Procedure

1. Turn off RF signal
2. Reduce V_G to -5.0V. Ensure $I_{DQ} \sim 0mA$
3. Set V_D to 0V
4. Turn off V_D supply
5. Turn off V_G supply

Evaluation Board (EVB) Layout Assembly



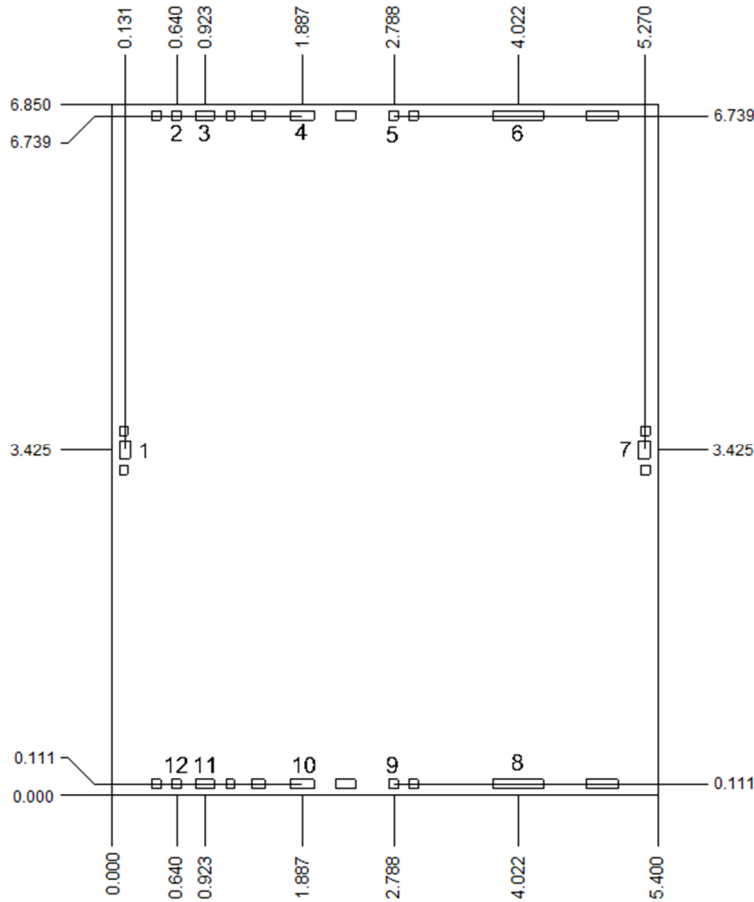
MMIC mounting/wire bonding detail

Notes: The MMIC must be biased from both sides top and bottom.

Bill of Materials

Reference Design	Value	Description	Manufacturer	Part Number
C1 – C10	100pF//10KpF	Cap, 30x30, 50V, Single Layer	Various	
C11 – C18	0.01uF	Cap, 0402, 50V, 10%, X7R	Various	
C19 – C26	10uF	Cap, 1206, 50V, 20%, X5R	Various	
R1 – R16	5.1Ω	Res, 0402, 50V, 5%, SMT	Various	

Mechanical Drawing & Bond Pad Description



Unit: millimeters
 Thickness: 0.10
 Die x, y size tolerance: +/- 0.050
 Chip edge to bond pad dimensions are shown to center of pad
 Ground is backside of die

Bond Pad Symbol	Pad Size	Description
1	RF In	0.115 x 0.190 RF Input; matched to 50Ω; DC blocked
2, 12	VG12	0.090 x 0.090 Gate voltage 1-2, bias network is required; see Application Circuit on page 11 as an example.
3, 11	VD1	0.190 x 0.090 Drain voltage 1, bias network is required; see Application Circuit on page 11 as an example
4, 10	VD2	0.235 x 0.090 Drain voltage 2, bias network is required; see Application Circuit on page 11 as an example.
5, 9	VG3	0.090 x 0.090 Gate voltage 3, bias network is required; see Application Circuit on page 11 as an example.
6, 8	VD3	0.508 x 0.090 Drain voltage 3, bias network is required; see Application Circuit on page 11 as an example.
7	RF Out	0.115 x 0.190 RF Output; matched to 50Ω; DC blocked

Assembly Notes

Component placement and adhesive attachment assembly notes:

- Vacuum pencils and/or vacuum collets are the preferred method of pick up.
- Air bridges must be avoided during placement.
- The force impact is critical during auto placement.
- Organic attachment (i.e. epoxy) can be used in low-power applications.
- Curing should be done in a convection oven; proper exhaust is a safety concern.

Reflow process assembly notes:

- Use AuSn (80/20) solder and limit exposure to temperatures above 300°C to 3-4 minutes, maximum.
- An alloy station or conveyor furnace with reducing atmosphere should be used.
- Do not use any kind of flux.
- Coefficient of thermal expansion matching is critical for long-term reliability.
- Devices must be stored in a dry nitrogen atmosphere.

Interconnect process assembly notes:

- Thermosonic ball bonding is the preferred interconnect technique.
- Force, time, and ultrasonic are critical parameters.
- Aluminum wire should not be used.
- Devices with small pad sizes should be bonded with 0.0007-inch wire.